

L Number	Hits	Search Text	DB	Time stamp
1	299119	mask or photomask or reticle	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
2	88978	multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
3	467370	reflection or reflective or reflect	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
4	94779	absorber	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
5	15270	(mask or photomask or reticle ) and multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
6	5668	multilayer same (reflection or reflective or reflect)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
7	784	absorber and ((mask or photomask or reticle ) and multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:09
8	51665	tantalum	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
9	110	(absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
10	362	(tantalum or ta) same absorber	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:10
11	27	((absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:14
12	2120	and ((tantalum or ta) same absorber) (chromium or cr) same multilayer	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:46
13	5	((((absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:16
14	2115	((chromium or cr) same multilayer) not (((absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:16
15	5	((chromium or cr) same multilayer) not (((chromium or cr) same multilayer) not (((absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum) and ((tantalum or ta) same absorber)) and ((chromium or cr) same multilayer)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:23
16	19	((absorber and ((mask or photomask or reticle ) and multilayer)) and tantalum) and ((chromium or cr) same multilayer)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:23
17	5510	(chromium or cr) same (reflection or reflective or reflect)	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:47
18	58	(absorber and ((mask or photomask or reticle ) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:47
19	26	tantalum and ((absorber and ((mask or photomask or reticle ) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50
20	5452	((chromium or cr) same (reflection or reflective or reflect)) not ((absorber and ((mask or photomask or reticle ) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50

21	58	((chromium or cr) same (reflection or reflective or reflect)) not ((chromium or cr) same (reflection or reflective or reflect)) not ((absorber and (mask or photomask or reticle ) and multilayer)) and ((chromium or cr) same (reflection or reflective or reflect)))	USPAT; US-PGPUB; EPO; JPO	2003/08/22 15:50
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